Atmospheric Oxidation Mechanism of Methyl Acetate

L. K. Christensen,* J. C. Ball, and T. J. Wallington*,[†]

Ford Research Laboratory, SRL-3083, Ford Motor Company, P.O. Box 2053, Dearborn, Michigan 48121-2053

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Smog chamber/FTIR techniques were used to study the Cl atom initiated oxidation of CH₃C(O)OCH₃ in 700 Torr of N₂/O₂ at 296 K. Relative rate techniques were used to measure $k(Cl+CH_3C(O)OCH_3) = (2.2 \pm 0.3) \times 10^{-12}$, $k(Cl+CH_3C(O)CH_3) = (2.2 \pm 0.4) \times 10^{-12}$, $k(Cl+CH_3C(O)OC(O)H) = (1.0 \pm 0.1) \times 10^{-13}$, and $k(Cl+ ClCH_2C(O)OCH_3) = (8.5 \pm 1.9) \times 10^{-13}$ cm³ molecule⁻¹ s⁻¹. The reaction of Cl+CH₃C(O)OCH₂O· radical was studied in 700 Torr of N₂/O₂ diluent at 296 K in the absence and presence of NO. Two loss mechanisms were identified: reaction with O₂ to give CH₃C(O)OC(O)H and α -ester rearrangement to give CH₃C(O)OH and HCO· radicals. It was found that α -ester rearrangement is more likely when CH₃C(O)-OCH₂O· radicals were produced via the CH₃C(O)OCH₂O₂· + NO reaction than when they were produced via the self-reaction of peroxy radicals. In one atmosphere of air ([O₂] = 160 Torr) containing NO at 296 K it can be calculated that 65 ± 14% of the CH₃C(O)OCH₂O· radicals undergo α -ester rearrangement while 35 ± 5% react with O₂.

1. Introduction

Esters are widely used in industry as solvents and during the manufacture of perfumes and food flavoring. They are volatile organic compounds (VOCs) and may be released into the atmosphere during their use (methyl acetate has a vapor pressure of 28.8 kPa at 298 K). Esters are also emitted into the atmosphere from natural sources (i.e., vegetation) and are formed in the atmosphere as oxidation products of ethers used as automotive fuel additives. Methyl acetate is produced during the atmospheric degradation of *tert*-amyl methyl ether (TAME) in a molar yield of 35%,¹ and from methyl *tert*-butyl ether (MTBE) in a molar yield of 15%.^{2,3} Despite their importance, the atmospheric oxidation mechanism of esters has received relatively little attention. To improve our understanding of the atmospheric chemistry of esters we report here the results of a study of the Cl atom initiated oxidation of methyl acetate.

The atmospheric oxidation of methyl acetate is initiated by reaction with OH radicals:

$$CH_3C(O)OCH_3 + OH \rightarrow CH_3C(O)OCH_2 + H_2O$$
 (1a)

$$CH_3C(O)OCH_3 + OH \rightarrow \cdot CH_2C(O)OCH_3 + H_2O$$
 (1b)

Under atmospheric conditions alkyl radicals produced in reaction 1 react with oxygen to give peroxy radicals:

$$CH_3C(O)OCH_2 \cdot + O_2 \rightarrow CH_3C(O)OCH_2O_2 \cdot$$
(2)

$$\cdot CH_2C(O)OCH_3 + O_2 \rightarrow \cdot O_2CH_2C(O)OCH_3 \qquad (3)$$

Peroxy radicals react with NO, NO₂, HO₂, and other peroxy radicals in the atmosphere.⁴ Reaction with NO dominates in

polluted air masses and is expected to give largely, if not exclusively, the corresponding alkoxy radical. In this work we have studied the fate of the $CH_3C(O)OCH_2O$ radical.

2. Experimental Section

All experiments were performed in a 140-liter Pyrex reactor interfaced to a Mattson Sirus 100 FTIR spectrometer.⁵ The reactor was surrounded by 22 fluorescent blacklamps (GE F15T8-BL) used to photochemically initiate the experiments. The oxidation of CH₃C(O)OCH₃ was initiated by reaction with Cl atoms generated by photolysis of molecular chlorine in 700 Torr of O₂/N₂ diluent at 296 \pm 2 K

$$Cl_2 + h\nu \rightarrow 2 Cl$$
 (4)

$$Cl + CH_3C(O)OCH_3 \rightarrow products$$
 (5)

Loss of CH₃C(O)OCH₃ and formation of products were monitored by Fourier transform infrared spectroscopy using an infrared path length of 28 m and a resolution of 0.25 cm⁻¹. Infrared spectra were derived from 32 to 128 co-added interferograms.

Calibration of ClCH₂C(O)OC(O)H, CH₃C(O)OC(O)H, CH₃C-(O)OH, and CO reference spectra was achieved by expanding known volumes of these compounds into the chamber. CH₃C-(O)OC(O)H was synthesized following the procedure of Schijf and Stevens.⁶ Ultrahigh purity N₂, O₂, and air diluent gases were obtained from Michigan Airgas Corp. All other reagents were obtained from Aldrich Chemical Co. at purities >99%. During calibration of the CH₃C(O)OH reference spectrum allowance was made for the presence of monomer and dimer in the vapor.⁷

In smog chamber experiments unwanted loss of reactants and products via photolysis, dark chemistry, and wall reactions has to be considered. Control experiments were performed to check for such unwanted losses of ClCH₂C(O)OC(O)H, CH₃C(O)-OCH₃, CH₃C(O)OC(O)H, and CH₃C(O)OH. During 14 min of

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[†] E-mail: twalling@ford.com.

UV irradiation 13% loss of ClCH₂C(O)OC(O)H was observed, from which a photolysis rate of $1.7 \times 10^{-4} \text{ s}^{-1}$ was calculated. No loss (<2%) of CH₃C(O)OCH₃, CH₃C(O)OC(O)H, or CH₃C-(O)OH was observed when these compounds were irradiated in air diluent, showing that photolysis and deposition on the chamber walls are not important. To check for hydrolysis of CH₃C(O)OC(O)H, reaction mixtures which had been subjected to photolysis (40–80% CH₃C(O)OCH₃ consumption) were left in the dark for 15–30 min; no loss of CH₃C(O)OC(O)H was observed.

3. Results

3.1 Relative Rate Studies of the Reactions of Cl Atoms with $CH_3C(O)OCH_3$, $CH_3C(O)CH_3$, $CH_3C(O)OC(O)H$, and $ClCH_2C(O)OCH_3$. Prior to investigating the atmospheric oxidation products of $CH_3C(O)OCH_3$, relative rate experiments were performed to determine the kinetics of reactions 5, 6, 7, and 8. Initial concentrations used were 10–12 mTorr CH_3C -(O)OCH_3, 9–39 mTorr $CH_3C(O)CH_3$, 3–6 mTorr $CH_3C(O)$ -OC(O)H, 4–9 mTorr $ClCH_2C(O)OCH_3$, 58–92 mTorr CH_3 - CH_2F , 35–240 mTorr CH_3Cl , 8–29 mTorr CH_3OCHO , 9–10 mTorr CH_4 , 2–3 mTorr CH_3F , and 10–258 mTorr of Cl_2 , in 700 Torr of air or N_2 diluent.

$$Cl + CH_3C(O)OCH_3 \rightarrow products$$
 (5)

$$Cl + CH_3C(O)CH_3 \rightarrow products$$
 (6)

 $Cl + CH_3C(O)OC(O)H \rightarrow products$ (7)

$$Cl + ClCH_2C(O)OCH_3 \rightarrow products$$
 (8)

Reaction 5 was measured relative to reactions 9, 10, and 11. Reaction 6 was measured relative to reactions 9, 10, 13, and 14. Reaction 7 was measured relative to reactions 10 and 12, and reaction 8 was measured relative to reaction 11

 $Cl + C_2H_5F \rightarrow products$ (9)

$$Cl + CH_3Cl \rightarrow products$$
 (10)

 $Cl + CH_3OC(O)H \rightarrow products$ (11)

 $Cl + CH_4 \rightarrow products$ (12)

 $Cl + CH_3F \rightarrow products$ (13)

 $Cl + C_2H_5Cl \rightarrow products$ (14)

The observed losses of CH₃C(O)OCH₃, CH₃C(O)CH₃, CH₃C-(O)OC(O)H, and ClCH₂C(O)OCH₃ versus those of reference compounds in the presence of Cl atoms are shown in Figures 1 and 2. Rate constant ratios were derived from linear least-squares analysis of the data in Figures 1 and 2; results are shown in Table 1. Values of k_5 , k_6 , k_7 , and k_8 were derived using $k_9 =$ 7.5×10^{-12} , $k_{10} = 4.9 \times 10^{-13}$, $k_{11} = 1.4 \times 10^{-12}$, $9 k_{12} = 1.0 \times 10^{-13}$, $8 k_{13} = 3.5 \times 10^{-13}$, $8 and k_{14} = 8.04 \times 10^{-12}$.¹⁰ We estimate that potential systematic errors associated with uncertainties in the reference rate constants add 10% uncertainty ranges for k_5 , k_6 , k_7 , and k_8 . We choose to cite final values of k_5 , k_6 , k_7 , and k_8 , which are the averages of the individual determinations given in Table 1. Hence, $k_5 = (2.2 \pm 0.3) \times 10^{-12}$, $k_6 = (2.2 \pm 0.4) \times 10^{-12}$, $k_7 = (1.0 \pm 0.1) \times 10^{-13}$, and $k_8 = (8.5 \pm 1.9) \times 10^{-13}$ cm³ molecule⁻¹ s⁻¹. Quoted errors



Figure 1. Upper panel: loss of $CH_3C(O)OCH_3$ versus C_2H_5F (triangles), CH_3Cl (circles), and $CH_3OC(O)H$ (squares) in the presence of Cl atoms in 700 Torr of air (open symbols) or N_2 (filled symbols) at 296 K. Lower panel: loss of acetone versus C_2H_5F (triangles), CH_3 -Cl (circles), CH_3F (squares), and C_2H_5Cl (diamonds). Experiments were performed at 296 K in 700 Torr of either O_2 (open symbols) or N_2 (filled symbols) diluent.

reflect both statistical uncertainties and potential systematic errors associated with the reference rate constants. Our value for k_5 is 23% lower than that of $k_5 = (2.85 \pm 0.35) \times 10^{-12}$ cm³ molecule⁻¹ s⁻¹ reported in the absolute rate study by Notario et al.¹¹

Two measurements of k_6 have been reported.^{12,13} Wallington et al.¹² used the relative rate technique to measure $k_6/k(\text{Cl} + \text{C}_2\text{H}_5\text{Cl}) = 0.295 \pm 0.015$. Using $k(\text{Cl} + \text{C}_2\text{H}_5\text{Cl}) = 8.04 \times 10^{-12} \text{ cm}^3$ molecule⁻¹ s⁻¹, a value of $k_6 = 2.4 \times 10^{-12} \text{ cm}^3$ molecule⁻¹ s⁻¹ was derived. As seen from Table 1, the results from the present work are consistent with the previous study at Ford.¹² Olsson et al. report a value of $k_6 = 1.7 \times 10^{-12} \text{ cm}^3$ molecule⁻¹ s⁻¹, ¹³ which is 23% lower than that measured here. Potential systematic errors associated with the study of Olsson et al. have been discussed previously.¹⁴ Based on the present work we recommend $k_6 = (2.2 \pm 0.4) \times 10^{-12} \text{ cm}^3$ molecule⁻¹ s⁻¹.

3.2 Mechanism of the Reaction of Cl Atoms with CH₃C-(O)OCH₃. To investigate the mechanism of reaction 5 experiments were performed using UV irradiation of CH₃C(O)OCH₃/ Cl₂/N₂ mixtures. Initial concentrations were 0.7-5 Torr Cl₂ and 11-54 mTorr CH₃C(O)OCH₃ in 700 Torr of N₂. Reaction mixtures were subjected to 3-5 successive irradiations each having a duration of 2-5 s. In such experiments ClCH₂C(O)-



Figure 2. Upper panel: loss of $CH_3C(O)OC(O)H$ versus CH_4 (triangles), and CH_3Cl (circles) in the presence of Cl atoms in 700 Torr of O₂ (open symbols) or N₂ (filled symbols) at 296 K. Lower panel: loss of $ClCH_2C(O)OCH_3$ versus $CH_3OC(O)H$ in the presence of Cl atoms in 700 Torr of air (open symbols) or N₂ (filled symbols) at 296 K.

OCH₃ and CH₃C(O)OCH₂Cl are produced by the following sequence of chain reactions:

 $Cl + CH_3C(O)OCH_3 \rightarrow CH_3C(O)OCH_2 + HCl$ (5a)

$$Cl + CH_3C(O)OCH_3 \rightarrow \cdot CH_2C(O)OCH_3 + HCl$$
 (5b)

 $CH_3C(O)OCH_2 \cdot + Cl_2 \rightarrow CH_3C(O)OCH_2Cl + Cl$ (15a)

$$\cdot CH_2C(O)OCH_3 + Cl_2 \rightarrow ClCH_2C(O)OCH_3 + Cl \quad (15b)$$

The yield of ClCH₂C(O)OCH₃ provides a measure of the importance of channel 5b. With the short irradiation times used in these experiments, loss of ClCH₂C(O)OCH₃ due to photolysis is insignificant and reaction 8 is too slow to be a significant loss of ClCH₂C(O)OCH₃. There was no observable formation of ClCH₂C(O)OCH₃ following irradiation of CH₃C(O)OCH₃/Cl₂/N₂ mixtures. Using the calibrated reference spectrum of ClCH₂C(O)OCH₃ an upper limit for the ClCH₂C(O)OCH₃ yield of 5% was established. We conclude that $k_{5b}/(k_{5a} + k_{5b}) < 0.05$ and, by inference, $k_{5a}/(k_{5a} + k_{5b}) > 0.95$.

3.3 Fate of the CH₃C(O)OCH₂O' Radical in the Absence of NO. To study the fate of the CH₃C(O)OCH₂O· radical, two sets of experiments were performed in which CH₃C(O)OCH₃/ Cl_2/O_2 and CH₃C(O)OCH₃/ $Cl_2/O_2/NO$ mixtures were subjected to UV irradiation. In the first set of experiments the oxidation

of methyl acetate was studied in the absence of NO. Initial concentrations of gas mixtures were 8-12 mTorr CH₃C(O)-OCH₃ and 13-311 mTorr Cl₂. Experiments were performed at a constant total pressure of 700 Torr in N_2 diluent with the O_2 partial pressure varied over the range 0.9-700 Torr. Typical spectra obtained before (A) and after (B) UV irradiation of a mixture containing 11.6 mTorr CH₃C(O)OCH₃, 17 mTorr Cl₂, and 147 Torr O₂ are shown in Figure 3. In all experiments three products, CH₃C(O)OC(O)H, CH₃C(O)OH, and CO, were readily identified and quantified using calibrated reference spectra. In addition an unknown product(s) which absorbs at 830, 966, 1027, 1220, 1780, and 3581 cm⁻¹ was observed, see Figure 3 panel G. As shown in Figure 4, the increase of CH₃C(O)OC-(O)H, CH₃C(O)OH, and CO scaled linearly with the loss of CH₃C(O)OCH₃, suggesting that secondary loss or formation of these products is insignificant. In contrast, inspection of Figure 4 shows that the unknown product(s) is subject to secondary loss processes in the chamber. The yield of the unknown product was estimated from the initial rate of its formation by assuming that it accounts for the balance of the methyl acetate loss.

Reaction of Cl atoms with methyl acetate in the presence of O_2 gives rise to peroxy radicals

$$Cl + CH_3C(O)OCH_3 \rightarrow CH_3C(O)OCH_2 + HCl$$
 (5a)

$$CH_3C(O)OCH_2 \cdot + O_2 \rightarrow CH_3C(O)OCH_2O_2 \cdot (2)$$

In the absence of NO, $CH_3C(O)OCH_2O$ radicals are formed by the peroxy radical self-reaction

$$2 \operatorname{CH}_3C(O)\operatorname{OCH}_2O_2 \cdot \rightarrow 2 \operatorname{CH}_3C(O)\operatorname{OCH}_2O \cdot + O_2$$
 (16a)

$$2 \operatorname{CH}_{3}C(O)\operatorname{OCH}_{2}O_{2} \cdot \rightarrow CH_{3}C(O)\operatorname{OC}(O)H + CH_{3}C(O)\operatorname{OCH}_{2}OH + O_{2}$$
(16b)

There are several possible fates of the CH₃C(O)OCH₂O· radical. They can react with oxygen to form acetic formic anhydride, reaction 17. Tuazon et al.¹⁵ have reported that alkoxy radicals of the structure RC(O)OCHO·R' can undergo α -ester rearrangement to RC(O)OH plus R'C(O)·. Evidence of α -ester rearrangement in CF₃C(O)OCHO·CF₃ radicals has been reported.¹⁶ In the case of CH₃C(O)OCH₂O· radicals α -ester rearrangement will give acetic acid and formyl radicals, reaction 18. The alkoxy radical could also decompose via C–O or C–H bond cleavage, reaction 19 or 20, and/or 1,5-H shift isomerization, reaction 21:

 $CH_3C(O)OCH_2O \cdot + O_2 \rightarrow CH_3C(O)OC(O)H + HO_2$ (17)

$$CH_3C(O)OCH_2O \rightarrow CH_3C(O)OH + HCO \rightarrow (18)$$

$$CH_3C(O)OCH_2O \rightarrow CH_3C(O)O + CH_2O$$
 (19)

$$CH_3C(O)OCH_2O \rightarrow CH_3C(O)OC(O)H + H$$
 (20)

$$CH_3C(O)OCH_2O \rightarrow CH_2C(O)OCH_2OH$$
 (21)

Yields of $CH_3C(O)OC(O)H$, $CH_3C(O)OH$, and CO observed from the Cl initiated oxidation of $CH_3C(O)OCH_3$ in the absence of NO are shown in Figure 5. The yield of $CH_3C(O)OC(O)H$ increases while the yield of $CH_3C(O)OH$ decreases with increasing oxygen concentration. This behavior reflects a competition between reactions 17 and 18. The observed CO

TABLE 1: Rate Constant Ratios for Reactions Involving Cl Atoms with Methyl Acetate, Acetone, Formic Acetic Anhydride, and Methyl Chloroacetate, Measured at 296 \pm 2 K

	CH ₃ C(O)OCH ₃		CH ₃ C(O)CH ₃		CH ₃ C(O)OC(O)H		ClCH ₂ C(O)OCH ₃	
ref	$k_5/k_{\rm ref}$	k_5^a	$k_6/k_{\rm ref}$	k_6^a	$k_7/k_{\rm ref}$	k_7^a	$k_8/k_{\rm ref}$	k_8^a
C ₂ H ₅ F CH ₃ Cl CH ₃ OCHO CH ₄	$\begin{array}{c} 0.297 \pm 0.032 \\ 4.09 \pm 0.33 \\ 1.62 \pm 0.16 \end{array}$	$\begin{array}{c} 22.3 \pm 3.3 \\ 20.0 \pm 2.6 \\ 22.7 \pm 3.2 \end{array}$	$\begin{array}{c} 0.288 \pm 0.017 \\ 4.69 \pm 0.16 \end{array}$	21.6 ± 2.5 23.0 ± 2.4	0.209 ± 0.017 1.04 ± 0.05	1.02 ± 0.13 1.04 ± 0.12	0.61 ± 0.12	8.5 ± 1.9
CH ₃ F C ₂ H ₅ Cl			$6.15 \pm 0.26 \\ 0.284 \pm 0.018$	21.5 ± 2.3 22.8 ± 2.7				

^{*a*} Units of 10^{-13} cm³ molecule⁻¹ s⁻¹, error limits include 10% uncertainty in $k_{ref.}$



Figure 3. IR spectra before (A) and after (B) a 1 min irradiation of a mixture of 11.6 mTorr of CH₃C(O)OCH₃, 17 mTorr Cl₂, 147 Torr O₂, and 553 Torr of N₂. The consumption of CH₃C(O)OCH₃ was 45%. Panel C shows the product spectrum obtained after subtraction of features attributable to CH₃C(O)OCH₃ from panel B. Panel D shows the reference spectrum of CH₃C(O)OC(O)H. Panel E shows the residual after subtraction of features attributable to CH₃C(O)OC(O)H. Panel E shows the residual after subtraction of features attributable to CH₃C(O)OC(O)H. Panel G shows the residual after subtraction of features attributable to CH₃C(O)OH. Panel G shows the residual after subtraction of features attributable to CH₃C(O)OH. Panel G shows the residual after subtraction of features attributable to CH₃C(O)OH. Panel G shows the residual after subtraction of features attributable to CH₃C(O)OH. Panel E.

yield decreases with decreasing O_2 concentration in a similar fashion as CH₃C(O)OH. This is consistent with the formation of formyl radicals in reaction 18, which react with O_2 to give CO and HO₂. Measured yields of CO were always slightly (\approx 0.07) higher than the yields of CH₃C(O)OH, but this difference is not significant within the experimental uncertainty. Any CH₃C(O)O• radicals formed by reaction 19 will decompose to form CO₂ and CH₃• radicals. Methyl radicals will be oxidized to give HCHO, CH₃OH, and CH₃OOH. Due to their rapid reaction with Cl atoms (20–30 times faster than reaction 5) HCHO, CH₃OH, and CH₃OOH will be converted into CO. The consistency between the CO and CH₃C(O)OH yields indicates that reaction 19 is insignificant. The combined yield of CH₃C-



Figure 4. Formation of $CH_3C(O)OH$ (filled circles), $CH_3C(O)OC-(O)H$ (open circles CO, (open triangles), and an unknown product believed to be $CH_3C(O)OCH_2OOH$ (filled triangles) versus loss of $CH_3C(O)OCH_3$, following UV irradiation of a mixture of 11.6 mTorr of $CH_3C(O)OCH_3$, 17 mTorr Cl_2 , 147 Torr O_2 , and 553 Torr of N_2 . The straight lines are linear least-squares fits. The curve is a second-order regression to aid visual inspection of the data trend.

(O)OH and $CH_3C(O)OC(O)H$ accounts for approximately 80% of reacted $CH_3C(O)OCH_3$, see Figure 5.

The CH₃C(O)OC(O)H yield shows a nonzero *y*-axis intercept in Figure 5. There are several potential explanations for this: (i) reaction 20 could be important, (ii) the molecular channel of the peroxy radical self-reaction (channel 16b) could be significant, (iii) the anhydride could be formed in the HO₂ + CH₃C(O)OCH₂O₂• reaction (channel 22b)

$$CH_{3}C(O)OCH_{2}O_{2} \cdot + HO_{2} \rightarrow CH_{3}C(O)OCH_{2}OOH + O_{2}$$
(22a)

Assuming that reactions 17 and 18 are the sole fate of CH₃C-(O)OCH₂O· radicals, the dependence of the CH₃C(O)OCH₃ and CH₃C(O)OH yields on $[O_2]$ can be expressed in terms of the rate constant ratio k_{17}/k_{18} . The yield of CH₃C(O)OC(O)H is given by

$$Y(CH_{3}C(O)OC(O)H) = Y(RO \cdot) \left(\frac{\frac{k_{17}}{k_{18}}[O_{2}]}{\frac{k_{17}}{k_{18}}[O_{2}] + 1} \right) + C \quad (I)$$



Figure 5. Yields of $CH_3C(O)OH$ (filled circles), $CH_3C(O)OC(O)H$ (open circles), CO (open triangles), and the combined yield of $CH_3C(O)OH$ and $CH_3C(O)OC(O)H$ (squares) versus the O₂ partial pressure following the UV irradiation of $CH_3C(O)OCH_3/Cl_2/N_2/O_2$ mixtures at 700 Torr total pressure and 296 K. Curves are least-squares fits of expressions I and II to the data, see text for details.

where Y(RO) is the yield of the CH₃C(O)OCH₂O radical. The term *C* in eq I accounts for formation of CH₃C(O)OC(O)H via channels that are independent of O₂ concentration, i.e., via reaction 16b and/or 22b. The yield of CH₃C(O)OH is given by

$$Y(CH_{3}C(O)OH) = Y(RO \cdot) \left(\frac{1}{\frac{k_{17}}{k_{18}}} [O_{2}] + 1 \right)$$
(II)

The curves in Figure 5 are least-squares fits of expressions I and II to the data. From the CH₃C(O)OH data in Figure 5 we derive $k_{17}/k_{18} = 0.0045 \pm 0.0005$ Torr⁻¹, and *Y*(RO•) = 0.54 \pm 0.01, while the CH₃C(O)OC(O)H data gives $k_{17}/k_{18} = 0.0059 \pm 0.0010$ Torr⁻¹, *Y*(RO•) = 0.57 \pm 0.03, and *C* = 0.21 \pm 0.01. The parameters derived from the CH₃C(O)OH and CH₃C(O)-OC(O)H yields are consistent.

The unknown product shown in panel G in Figure 3 was not observed in the presence of NO (see section 3.4) suggesting that it is either CH₃C(O)OCH₂OH formed by the self-reaction of the peroxy radicals or CH₃C(O)OCH₂OOH formed in reaction 22. To distinguish between these two possibilities mixtures of 8.5-12.6 mTorr CH₃C(O)OCH₃, 96-277 mTorr Cl₂, 0.9-15 Torr H₂, and 131-136 Torr O₂ in 700 Torr N₂ diluent were introduced into the reaction chamber and irradiated using the UV fluorescent lamps. Experiments were performed where the initial concentration ratio [H₂]/[CH₃C(O)OCH₃] was increased from 0 to 1800. The chlorine atoms react with CH₃C(O)OCH₃ and H₂ to give CH₃C(O)OCH₂• radicals and H atoms, which then add O₂ to give CH₃C(O)OCH₂O₂• and HO₂ radicals:

$$Cl + CH_3C(O)OCH_3 \rightarrow HCl + CH_3C(O)OCH_2$$
 (5a)

$$Cl + H_2 \rightarrow HCl + H$$
 (23)

Increasing the $[H_2]/[CH_3C(O)OCH_3]$ ratio increases the flux of HO₂ radicals in the system. This increases the importance of reaction with HO₂ and decreases the self-reaction as a loss mechanism for the peroxy radicals. The only products observed in these experiments were CH₃C(O)OC(O)H, CH₃C(O)OH, CO,



Figure 6. Yields of $CH_3C(O)OH$ (filled circles), $CH_3C(O)OC(O)H$ (open circles), CO (open triangles), and the combined yield of CH_3C -(O)OH and $CH_3C(O)OC(O)H$ (squares) versus the O₂ partial pressure following the UV irradiation of NO/CH₃C(O)OCH₃/Cl₂/N₂/O₂ mixtures at 700 Torr total pressure and 296 K. Curves are least-squares fits of expressions I and III to the data, see text for details.

and the unknown. As the $[H_2]/[CH_3C(O)OCH_3]$ ratio increased from 0 to 1800, the observed yield of the unknown increased by a factor of 2, suggesting that it is a hydroperoxide. The residual spectrum is consistent with that expected of a hydroperoxide. A very weak absorption feature is observed at 830 cm⁻¹, which is assigned to the OO stretching vibration. The observed feature at 3581 cm⁻¹ is assigned to the O–H stretching vibration.

3.4 Fate of the CH₃C(O)OCH₂O[•] Radical in the Presence of NO. The oxidation of methyl acetate was also studied in the presence of NO. Initial concentrations used were 6-13 mTorr CH₃C(O)OCH₃, 6-185 mTorr Cl₂, and 3-14 mTorr NO. The experiments were performed at a constant total pressure of 700 Torr in N₂ diluent with the O₂ partial pressure varied over the range 1.8-628 Torr. In the presence of NO the CH₃C(O)-OCH₂O[•] radicals are formed by reaction 24a:

$$CH_{3}C(O)OCH_{2}O_{2} \cdot + NO \rightarrow CH_{3}C(O)OCH_{2}O \cdot + NO_{2}$$
(24a)

$$CH_3C(O)OCH_2O_2 \cdot + NO \rightarrow CH_3C(O)OCH_2ONO_2$$
 (24b)

In all experiments CH₃C(O)OC(O)H, CH₃C(O)OH, and CO were identified and quantified using their calibrated reference spectra. The observed yields of the three products are plotted versus the O₂ concentration in Figure 6. The yield of CH₃C-(O)OH decreases with increasing oxygen concentration while the CH₃C(O)OC(O)H yield increases. In the presence of NO, the CH₃C(O)OCH₂O₂· radicals are scavenged by reaction 24 and HO₂ radicals are scavenged by reaction with NO. A nonzero intercept in the CH₃C(O)OC(O)H yield would be evidence of reaction 20. The intercept in the CH₃C(O)OC(O)H yield is less than 0.05, and we conclude that reaction 20 is of minor importance.

In all experiments the [NO]/[O₂] concentration ratio was kept below 5×10^{-3} to suppress possible formation of nitrites and nitrates via addition of NO or NO₂ to the alkoxy radicals. No change in the product yields were observed when the initial NO concentration was decreased by a factor of 3 using high (620 Torr) and low (1.8 Torr) O_2 concentrations. Formation of nitrites or nitrates is of minor importance (less than 15%) for the data shown in Figure 6. The combined yields of CH₃C(O)-OC(O)H and CH₃C(O)OH account for 87 ± 15% of the reacted methyl acetate.

A least-squares fit of equation I to the CH₃C(O)OC(O)H data in Figure 6 gives $k_{17}/k_{18} = 0.0058 \pm 0.0009 \text{ Torr}^{-1}$, $Y(\text{RO}^{\bullet}) =$ 0.65 ± 0.03 , and $C = 0.04 \pm 0.04$. The value of k_{17}/k_{18} derived here is consistent with that derived from the data in the absence of NO in Figure 5, but the yield of the alkoxy radical is significantly less than 100%. Comparison of the CH₃C(O)OH data in Figures 5 and 6 shows that the CH₃C(O)OH yield is uniformly higher in the presence of NO. In the presence of NO there appears to be a contribution to the CH₃C(O)OH yield that is independent of the O₂ concentration.

A possible explanation for the experimental observations is that the reaction of CH₃C(O)OCH₂O₂• with NO produces excited alkoxy radicals, CH₃C(O)OCH₂O^{*}•, which are more prone to decompose to give CH₃C(O)OH than their counterparts produced in the less exothermic peroxy radical self-reaction. Tuazon et al.¹⁵ suggested that α -ester rearrangement proceeds via a five-membered transition state. The five-membered ring



is expected to have a ring strain of ≈ 6 kcal mol⁻¹,¹⁵ and α -ester rearrangement will have a substantial activation barrier. Assuming reaction 24 leads to formation of a significant fraction of excited alkoxy radicals CH₃C(O)OCH₂O*• that possess internal energy exceeding that necessary to overcome the barrier for α -ester rearrangement, the mechanism can be described as follows:

$$CH_{3}C(O)OCH_{2}O_{2} \cdot + NO \rightarrow CH_{3}C(O)OCH_{2}O^{*} \cdot + NO_{2}$$
(24)

 $CH_3C(O)OCH_2O^* \rightarrow CH_3C(O)OH + HCO^*$ (25)

 $CH_3C(O)OCH_2O^{*\bullet} + M \rightarrow CH_3C(O)OCH_2O^{\bullet} + M$ (26)

 $CH_3C(O)OCH_2O \cdot + O_2 \rightarrow CH_3C(O)OC(O)H + HO_2$ (17)

$$CH_3C(O)OCH_2O \rightarrow CH_3C(O)OH + HCO \rightarrow (18)$$

Some fraction of the excited alkoxy radicals undergoes prompt α -ester rearrangement via reaction 25; the remainder will lose their energy through collision with a third body M via reaction 26. Similar chemical activation effects have been reported for other alkoxy radicals (e.g., CF₃CFHO•,¹⁷ HOCH₂CH₂O•,¹⁸ CH₂-CIO•¹⁹). The yield of acetic acid can be expressed as

$$Y(CH_{3}C(O)OH) = Y(RO \cdot) \left(\frac{1}{\frac{k_{17}}{k_{18}}[O_{2}] + 1}\right) + Y \cdot$$
(III)

where $Y(\text{RO} \cdot)$ is the fraction of the alkoxy radicals that becomes thermalized and Y^* is the yield of the alkoxy radicals which undergoes prompt α -ester rearrangement to give CH₃C(O)OH. A nonlinear least-squares fit of equation III to the CH₃C(O)-OH data in Figure 6 gives $k_{17}/k_{18} = 0.0052 \pm 0.0022$ Torr⁻¹, $Y(\text{RO} \cdot) = 0.61 \pm 0.08$, and $Y^* = 0.20 \pm 0.08$. Averaging parameters derived from the two data sets shown in Figure 6 give $Y(\text{RO}\cdot) = 0.63 \pm 0.10$. It is gratifying that consistent values of k_{17}/k_{18} are derived from the CH₃C(O)OH and CH₃C(O)OC-(O)H data shown in Figures 5 and 6. Averaging the four determinations gives $k_{17}/k_{18} = 0.0054 \pm 0.0022 \text{ Torr}^{-1}$. In one atmosphere of air ([O₂] = 160 Torr) containing NO at 296 K it can be calculated that 65 ± 14% of the CH₃C(O)OCH₂O· radicals undergo α -ester rearrangement while 35 ± 5% react with O₂.

4. Implications for Atmospheric Chemistry

In the atmosphere $CH_3C(O)OCH_3$ can be removed by reaction with OH radicals and Cl atoms, photolysis, and/or wet/dry deposition. The kinetics of the reaction of OH radicals with CH₃C(O)OCH₃ have been the subject of three investigations.^{1,20,21} The reported rate constants are in good agreement $k_1 = (3.85 \pm 0.16) \times 10^{-131}, (3.22 \pm 0.26) \times 10^{-13}, (3.22 \pm 0$ $(3.41 \pm 0.29) \times 10^{-13} \text{ }^{21} \text{ cm}^3 \text{ molecule}^{-1} \text{ s}^{-1}$. Assuming an atmospheric lifetime for methane of 9 years²² and a rate constant for the CH₄ + OH reaction of 6.3×10^{-15} cm³ molecule⁻¹ s⁻¹ leads to an estimate for the atmospheric lifetime of CH₃C(O)-OCH₃ against reaction with OH of 60 days. As discussed by Notario et al.,¹¹ for typical atmospheric concentrations of Cl atoms and OH radicals, reaction with Cl atoms is a negligible loss process of CH₃C(O)OCH₃ compared to reaction with OH radicals. As discussed by Nriagu,23 the low Henry's law coefficients of esters ($K_{\rm H} = 8 \text{ M} \text{ atm}^{-1}$ for methyl acetate) probably preclude wet deposition from being a significant atmospheric loss mechanism for methyl acetate. Photolysis of methyl acetate is only important below 240 nm²⁴ and will not be of any significance in the lower atmosphere.

In the present work we have used Cl atoms to initiate oxidation of CH₃C(O)OCH₃, whereas in the atmosphere initiation is provided by OH radical attack. There are no available data concerning the relative importance of attack of OH radicals on the two different -CH₃ groups in CH₃C(O)OCH₃. In the present study we show that the majority of Cl atom reaction occurs at the -OCH₃ group. OH radicals are six times less reactive than Cl atoms toward CH₃C(O)OCH₃, and it seems reasonable to suppose that OH radicals will be more discriminating than Cl atoms. Structure-reactivity relationships²⁵ also suggest that the majority (70%) of OH attack will proceed at the $-OCH_3$ group. Hence, we conclude that the reaction with OH gives predominantly the alkyl radical CH₃C(O)OCH₂• which is rapidly converted into the corresponding peroxy radical CH₃C-(O)OCH₂O₂. As with other alkyl peroxy radicals, the atmospheric fate of CH₃C(O)OCH₂O₂• radicals will be reaction with either NO, NO₂, HO₂, or other peroxy radicals. Reaction of $CH_3C(O)OCH_2O_2$ radicals with NO₂ gives a thermally unstable peroxy nitrate which will decompose to regenerate the CH₃C-(O)OCH₂O₂• radicals. Reaction of CH₃C(O)OCH₂O₂• radicals with NO produces the alkoxy radical CH₃C(O)OCH₂O. We show here that under atmospheric conditions there are two competing loss processes for CH₃C(O)OCH₂O· radicals; decomposition via α -ester rearrangement to give CH₃C(O)OH and HCO radicals, or reaction with O_2 to give $CH_3C(O)OCHO$. Chemical activation plays an important role in the fate of CH₃C-(O)OCH₂O· radicals. A significant fraction, 20/(20 + 61) =25%, of CH₃C(O)OCH₂O· radicals produced in reaction 24a have sufficient internal excitation to undergo prompt decomposition via α -ester rearrangement. The remaining 75% of the CH₃C(O)OCH₂O· radicals are collisionally stabilized and then either react with O₂ or undergo thermal decomposition via α -ester rearrangement. In one atmosphere of air ([O₂] = 160 Torr) containing NO at 296 K it can be calculated that 65 \pm Atmospheric Oxidation Mechanism of Methyl Acetate

14% of the CH₃C(O)OCH₂O· radicals undergo α -ester rearrangement while 35 \pm 5% react with O₂.

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